



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Fumitaka Sugaya

Serial No.: 09/387,857

Art Unit: 2822

Filed: September 1, 1999

Examiner: C. Novacek

For: A SEMICONDUCTOR
DEVICE AND A METHOD
OF MANUFACTURING THE
SAME

Atty Docket: 21776/0039

#6/B
1-H-08
Kuyton
12/27/2001

RESPONSE AND AMENDMENT UNDER 37 CFR § 1.111

Commissioner for Patents
Washington, D.C. 20231

Sir:

In response to the Office Action dated September 11, 2001, please amend the above-identified application as follows:

IN THE TITLE

Please amend the title to read --A METHOD FOR FABRICATING A SEMICONDUCTOR STORAGE DEVICE HAVING AN INCREASED DIELECTRIC FILM AREA--.

IN THE SPECIFICATION

Kindly amend the specification as follows:

On page 2, prior to "BACKGROUND OF THE INVENTION", insert the following sentence: